



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 9635**  
Satoshi MAEMORI et al. : Docket No. 2001\_1300A  
Serial No. 09/955,111 : Group Art Unit 1752  
Filed September 19, 2001 : Examiner Sin Lee

POSITIVE-WORKING PHOTORESIST  
COMPOSITION AND PHOTSENSITIVE  
MATERIAL USING SAME

PETITION FOR EXTENSION OF TIME

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of September 5, 2003.

The fee of \$950.00 is

- ☒ submitted herewith.  
☐ to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.  
☐ Small entity status of this application is established by a Small Entity Status Assertion which  
☐ is enclosed.  
☐ has been previously submitted.

Respectfully submitted,

Satoshi MAEMORI et al.

03/05/2004 HVUONG1 00000149 09955111

02 FC:1253

950.00 DP

By Matthew M. Jacob  
Matthew M. Jacob  
Registration No.25,154  
Attorney for Applicants

MJ/da  
Washington, D.C. 20006-1021  
Telephone (202) 721-8200  
Facsimile (202) 721-8250  
March 4, 2004

RECEIVED  
MAR 09 2004

RECEIVED  
APR 21 2004  
TC 1700